



THE UNITED STATES PATENT AND TRADEMARK OFFICE

Patent Application Serial No. 10/629,011
Filing Date July 28, 2003
Inventor Trung Tri Doan et al.
Assignee Micron Technology, Inc.
Group Art Unit 2812
Examiner Jennifer M. Kennedy
Attorney's Docket No. MI22-2359
Title Atomic Layer Deposition Methods

SUPPLEMENTAL INFORMATION DISCLOSURE STATEMENT

References -- See Attached Form PTO-1449

In compliance with 37 C.F.R. §§ 1.56, 1.97 and 1.98, your attention is directed to the United States patents and other references listed on the attached Form PTO-1449. Copies of the required cited art references are attached. No admission is made regarding whether all the submitted references are prior art.

This Supplemental Information Disclosure Statement is being filed before the mailing of a first office action after the filing of a Request for Continued Examination. Therefore, no fee is believed to be required. However, in the event that a fee is required for filing this Supplemental Information Disclosure Statement, please charge the fee specified under 37 C.F.R. § 1.17(p) to Deposit Account No. 23-0925.

Respectfully submitted,

Dated: 1-23-06

By: 
Mark S. Matkin
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Form PTO-1449		U.S. DEPARTMENT OF COMMERCE PATENT AND TRADEMARK OFFICE			ATTY. DOCKET NO. MI22-2359		SERIAL NO. 10/629,011		
					APPLICANT: Trung Tri Doan et al.				
		FILING DATE July 28, 2003		GROUP ART UNIT 2812					
U.S. PATENT DOCUMENTS									
*Examiner's Initials		Document Number	Date	Name		Class	Subclass	Filing Date If Appropriate	
	AA	6,847,003 B2	01/25/05	Ishii et al.					
	AB								
	AC								
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	AE								
	AF								
	AG								
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FOREIGN PATENT DOCUMENTS									
		Document Number	Date	Country		Class	Subclass	Translation	
	AJ							Yes	No
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OTHER REFERENCES (including Author, Title, Date, Pertinent Pages, Etc.)									
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